

## Supporting Information

### **Realizing a colorful polymer solar cell with high color purity via a metal alloy- dielectric-metal alloy electrode**

Sajar Biring<sup>a,b</sup>, Abdul Khalik Akbar<sup>a,b</sup>, Dian Luo<sup>c</sup>, Yi-Nan Lin<sup>a</sup>, Goutam Kumar Dalapati<sup>a,d</sup>, and Shun-Wei Liu<sup>a,b\*</sup>

<sup>a</sup>Organic Electronics Research Center and Department of Electronic Engineering, Ming Chi University of Technology, New Taipei City 24301, Taiwan.

<sup>b</sup>Department of Electronic Engineering, Ming Chi University of Technology, New Taipei City 24301, Taiwan.

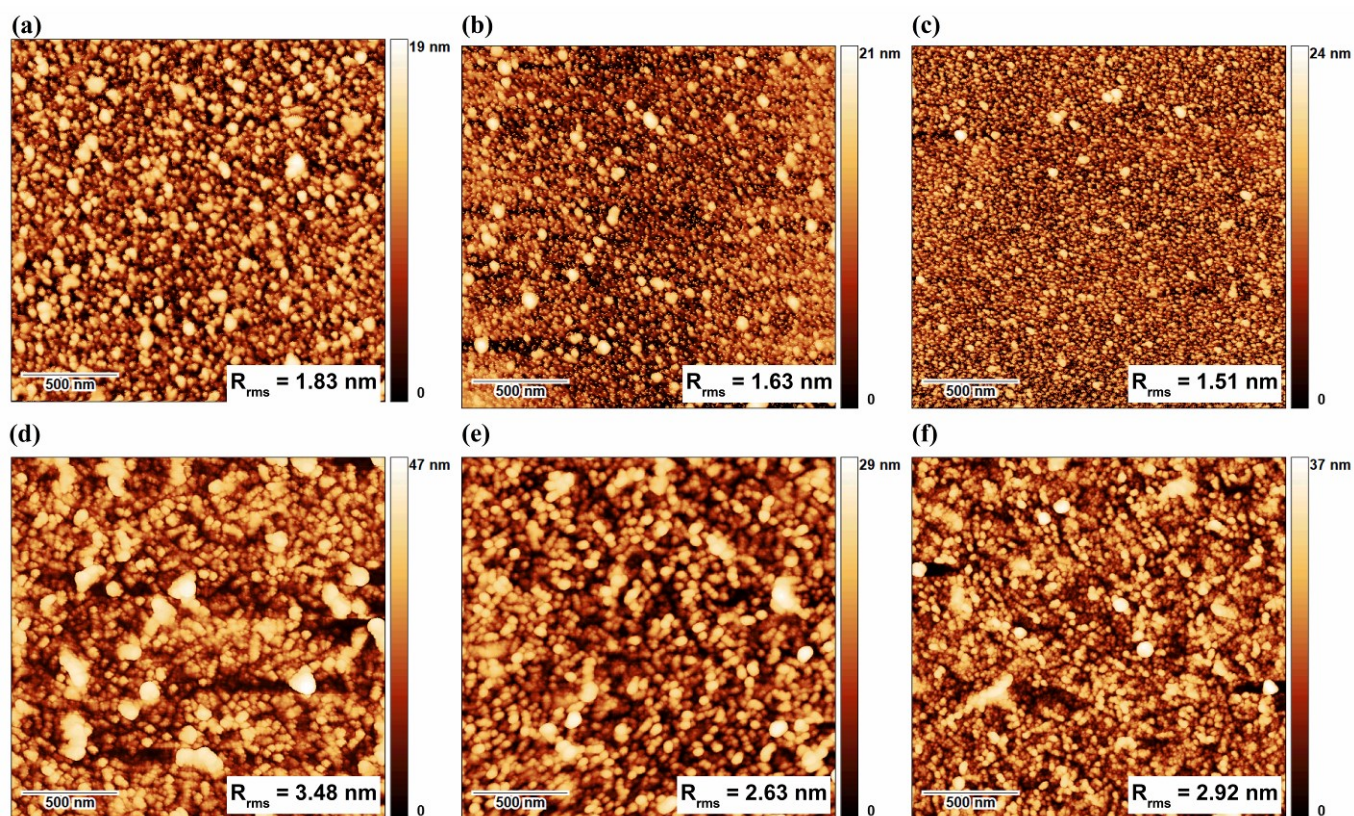
<sup>c</sup>Institute of Lighting and Energy Photonics, National Chiao Tung University, Tainan 71150, Taiwan.

<sup>d</sup>Department of Physics, SRM University-AP, Amaravati 522502, India.

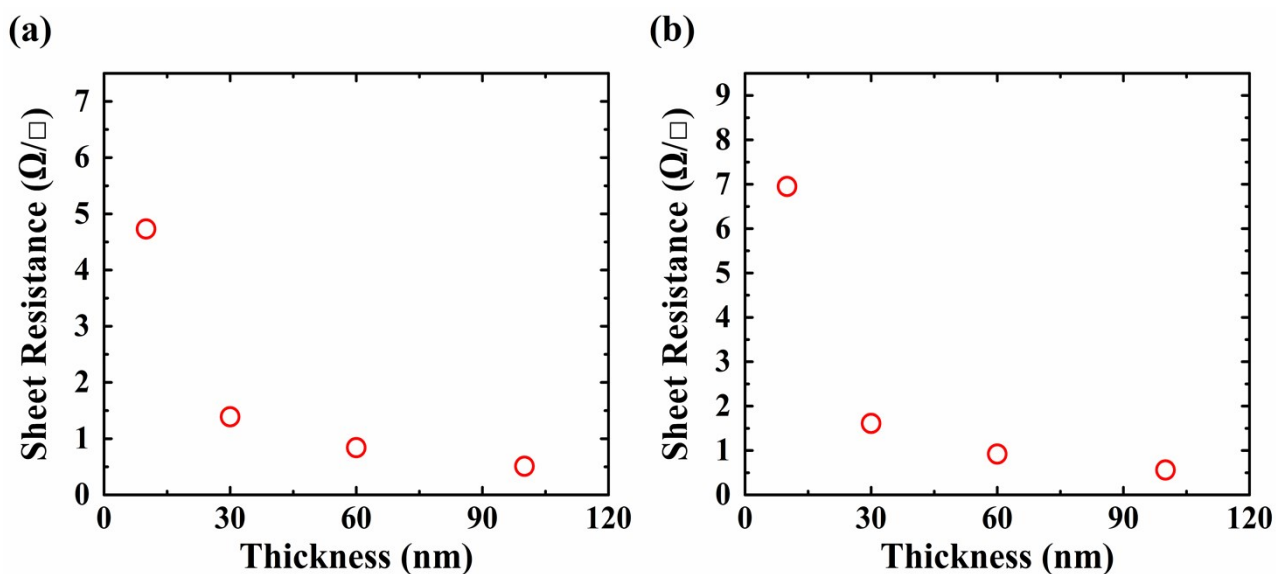
\*Corresponding authors:

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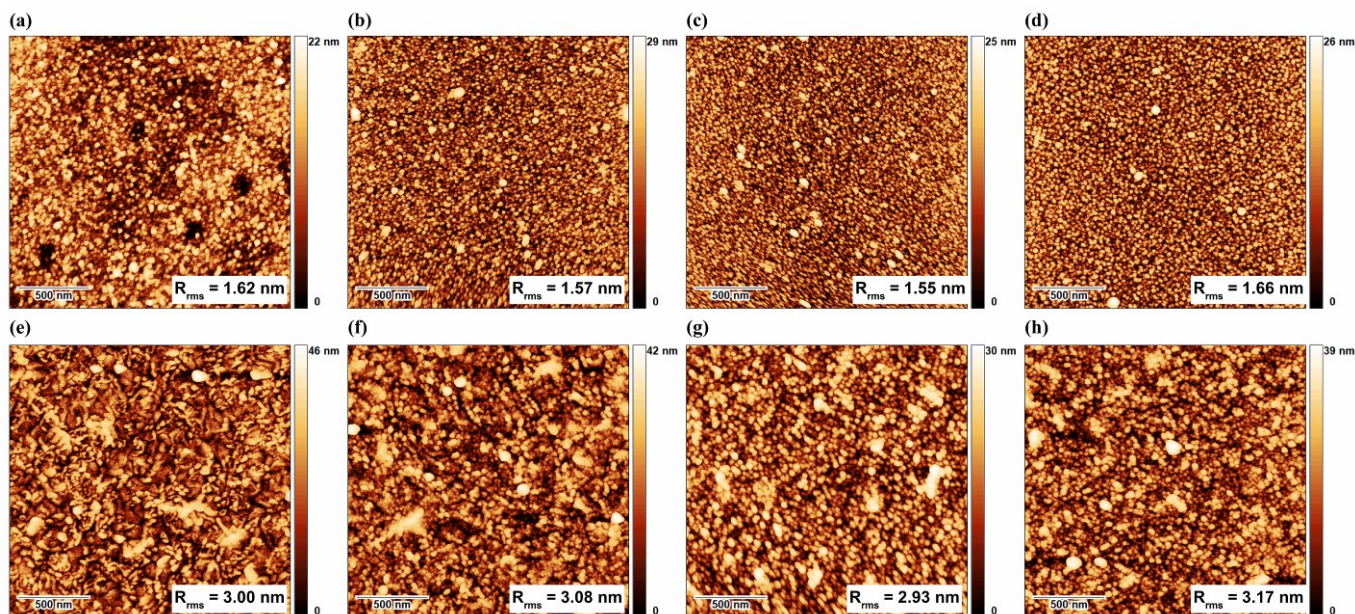
[swliu@mail.mcut.edu.tw](mailto:swliu@mail.mcut.edu.tw) (S.-W. Liu)



**Fig. S1** The film morphology of 30 nm metal film (a) Ag, (b) Cu:Ag, (c) Al:Ag deposited on 7 nm MoO<sub>3</sub> and (d) Ag, (e) Cu:Ag, (f) Al:Ag deposited on 75 nm HAT-CN.



**Fig. S2** The sheet resistance vs thickness of Al:Ag was deposited on (a) MoO<sub>3</sub> and (b) HAT-CN.



**Fig. S3** The different thickness of Al:Ag for (a) 10 nm, (b) 30 nm, (c) 60 nm, (d) 100 nm deposited on 7 nm MoO<sub>3</sub> and (e) 10 nm, (f) 30 nm, (g) 60 nm and (h) 100 nm deposited on 75 nm HAT-CN.

**Table S1** Summary on transmissive colorful solar cells with various FP structures

Structure	Electrode	Highest PCE (%)	Ref
ITO/PEDOT:PSS/MoO <sub>3</sub> /DTDCPB/DTDCPB:C <sub>70</sub> /C <sub>70</sub> /Bphen	Ag/NPB/Ag	5.15%	42
ITO/PEDOT:PSS/PTB7-Th:PC <sub>71</sub> BM/ZnO/Sb <sub>2</sub> O <sub>3</sub>	Ag/Sb <sub>2</sub> O <sub>3</sub> /Ag	7.03%	43
ITO/PEDOT:PSS/PTB7-Th:IEICO-4F/ZnO/Ag	Sb <sub>2</sub> O <sub>3</sub> /Ag/Sb <sub>2</sub> O <sub>3</sub>	7.88%	44
ITO/PEDOT:PSS/PM6:Y6/Bis-FIMG	Ag/TeO <sub>2</sub> /Ag	14.60%	45
ITO/PEDOT:PSS/PM6:N3:PC <sub>71</sub> BM/PDINO	Al:Ag/dielectric stack/Al:Ag/dielectric stacks/carbon fluoride (CF)	15.07%	46
ITO/ZnO/PTB7-Th:ITIC/MoO <sub>3</sub>	Ag/TiO <sub>2</sub> -AcAc/Ag	5.96%	47
ITO/ZnO/PTB7-Th:PC <sub>71</sub> BM/MoO <sub>3</sub>	Ag/ITO/Ag	8.20%	48
ITO/ZnO/PTB7-Th:PC <sub>71</sub> BM/MoO <sub>3</sub>	Au/Ag/WO <sub>3</sub> /Ag	9.02%	49
ITO/ZnO/PM7:PTTtID-Cl:IT-4F/MoO <sub>3</sub>	Ag/ITO/Ag	9.10%	50
ITO/ZnO/PEIE/PM6:Y6/MoO <sub>3</sub>	Ag/HAT-CN/Ag	13.28%	51
ITO/PEDOT:PSS/MAPbI <sub>3-x</sub> Cl <sub>x</sub> /PC <sub>61</sub> BM	Ag/ITO/Ag	7.60%	52
ITO/NiO/MAPbI <sub>3</sub> /PCBM/BCP	Ag/SiO <sub>2</sub> /ZnS/Ag/ZnS	11.18%	53
ITO/ZnO/PM6:Y6/MoO <sub>3</sub>	Al:Ag/HAT-CN/Al:Ag	13.62%	This work